Electron Interactions With BCl₃

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(Received 27 December 2001; revised 17 June 2002; accepted 1 July 2002; published 31 October 2002)

In this paper we review and assess the cross sections for collisions of low-energy electrons with boron trichloride (BCl₃). The only available experimental cross section data are for partial and total ionization and electron attachment, and the electron attachment cross sections are uncertain. Calculated values are available for the total elastic, differential elastic, and momentum transfer cross sections, and derived cross sections have been published for vibrational excitation and dissociation. Other than some rather uncertain data on electron attachment rate constants and some measurements of electron drift velocities in BCl₃/Ar and BCl₃/He mixtures, there are no measurements of the electron attachment, ionization, or transport coefficients for this gas. Analysis of the experimental data on the electron affinity, electron attachment, and electron scattering, enabled identification of negative ion states of BCl₃ at about -0.3, 1.0, 2.8, 5.2, 7.6, and 9.0 eV. Because the existing electron collision data are few and uncertain, relevant data are provided for photon impact on BCl₃. (DOI: 10.1063/1.1504440]

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1. Introduction

In earlier papers in this series we have pointed out the significance of electron collision data to models intended to aid in developing plasma processing techniques for the microelectronics industry. Modeling of such plasmas is often hindered by the absence of reliable electron-collision data. In our continuing effort to provide such data, we focus in this paper on boron trichloride (BCl₃).

The BCl₃ molecule is a major source of reactive radicals generated via electron-impact dissociative processes, including electron attachment. For this reason, it is widely used as a plasma processing gas in the etching of metals (e.g., aluminum) and semiconductors (e.g., GaAs and Si) (see, for example, Refs. 1–7). BCl₃ is used in a variety of gas mixtures (i.e., BCl₃ mixed with Ar, N₂, Cl₂, SF₆, CF₄, CHF₃, Ar+O₂, Ar+Cl₂, Ar+CCl₂F₂, Ar+SF₆, Ar+H₂+N₂, SiCl₄+H₂, and Ar+Cl₂+N₂) for the etching of GaAs, GaSb, GaN, GaP, InAs, InP, AlGaAs, AlGaP, AlGaN, AlInAs, AlInP, InGaAs, InGaP, InAlP, InAlN, NiMnSb, and InGaAsP (e.g., see Refs. 7–13).

In this paper we review, assess, synthesize, discuss, and suggest cross sections for collisions of low-energy electrons with the BCl₃ molecule. The high reactivity and corrosiveness of the BCl₃ gas make experimental measurements difficult and partially account for the meager electron collision cross section data that are available for this gas at this time and their large uncertainties. Besides some rather uncertain data on electron attachment rate constants for BCl₃ (see Sec. 5) and some measurements of the electron drift velocity in BCl₃/Ar and BCl₃/He mixtures,¹⁴ there are no measurements of the electron attachment, ionization, or transport coefficients for this gas. Because the existing electron collision data are few and uncertain, we provide relevant data involving photon impact with the BCl3 molecule. For calculated cross sections for some electron collision processes for the BCl and BCl₂ fragments see McKoy et al.¹⁵

The review procedure followed in this paper is similar to that in our earlier studies.^{16–25} In Table 1 are listed the cross sections and rate coefficients discussed in this paper along with their symbols and units.

2. Structural and Electronic Properties

Boron trichloride (BCl₃) is a nonpolar, plane symmetric $(D_{3h} \text{ symmetry})$ molecule.²⁶ Its ground state outer valence orbital configuration^{27,28} molecular shell is: $(2a'_1)^2(2e')^4(1a''_2)^2(3e')^4(1e'')^4(1a'_2)^2X^1A'_1$. The outermost three $(1a'_2, 1e'', and 3e')$ occupied valence orbitals are nonbonding (Cl lone pair), the $1a_2''$ orbital is B-Cl π bonding, and the $2a'_1$ and 2e' are B-Cl σ bonding. These six orbitals have binding energies between 10 and 20 eV.²⁷ The lowest unoccupied molecular orbital of the BCl3 molecule is $2a_2''(B 2p - Cl 3p \pi^*)$, and the next two higher-lying empty orbitals are $3a'_1$ and 4e' (B 2p-Cl $3p\sigma^*$).^{29,30} The presence of these unoccupied molecular orbitals helps explain the observed negative ion states of the BCl₃ molecule, and consequently the observed or calculated structure in the electron scattering and electron attachment cross sections. A detailed calculation by Baeck and Bartlett²⁹-optimizing bond lengths and bond angles within D_{3h} symmetry for BCl₃ and C_{3y} symmetry for BCl₃—provided a number of structural and electronic parameters such as ionization energies, electronic vertical excitation energies, and vibrational frequencies for the BCl₃, BCl₃⁻, BCl₃⁺ species.²⁹

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TABLE 1. Definition of symbols

| Symbol | Definition | Common scale and units | | |
|--------------------------------------|--|--|--|--|
| $\sigma_{\rm pa,t}(\lambda)$ | Total photoabsorption cross section | $10^{-18} \mathrm{cm}^2; 10^{-22} \mathrm{m}^2$ | | |
| $\sigma_{\rm sc,t}(\epsilon)$ | Total electron scattering cross section | $10^{-16} \mathrm{cm}^2; 10^{-20} \mathrm{m}^2$ | | |
| $\sigma_{e,t}(\epsilon)$ | Total elastic electron scattering cross section to poloadada | $10^{-16} \mathrm{cm}^2; 10^{-20} \mathrm{m}^2$ | | |
| $\sigma_{\rm e,partial}(\epsilon)$ | Partial elastic electron scattering cross section | $10^{-16} \mathrm{cm}^2; 10^{-20} \mathrm{m}^2$ | | |
| $\sigma_{\rm e.diff}(\epsilon)$ | Elastic differential electron scattering cross section | $10^{-16} \mathrm{cm}^2 \mathrm{sr}^{-1}$ | | |
| $\sigma_{\rm m}(\epsilon)$ | Momentum transfer cross section (elastic) | $10^{-16} \mathrm{cm}^2; 10^{-20} \mathrm{m}^2$ | | |
| $\sigma_{	ext{i,partial}}(\epsilon)$ | Partial ionization cross section | $10^{-16} \mathrm{cm}^2; 10^{-20} \mathrm{m}^2$ | | |
| $\sigma_{i,i}(\epsilon)$ | Total ionization cross section | $10^{-16} \mathrm{cm}^2; 10^{-20} \mathrm{m}^2$ | | |
| $\sigma_{\rm a,t}(\epsilon)$ | Total electron attachment cross section | $10^{-16} \mathrm{cm}^2; 10^{-20} \mathrm{m}^2$ | | |
| $k_{at}(E/N)$ | Total electron attachment rate constant | $10^{-9} \text{ cm}^3 \text{ s}^{-1}$ | | |
| w(E/N) | Electron drift velocity | $10^{6} \mathrm{cm}\mathrm{s}^{-1}$ | | |
| | | Judge Institut | | |

A number of experimental studies contribute to an understanding of the molecular and electronic structure of the BCl₃ molecule. These include electron-impact excitation and ionization,^{31–33} negative-ion formation,^{31–37} electron-impact dissociation into excited fragments,^{38–40} photoelectron spectra,^{28,41,42} photoionization and photodissociation,^{43–49} and photoabsorption and fluorescence measurements in the ultraviolet/visible (UV/VIS) region.^{44–52} Some of the photophysical studies incorporated mass analysis and fluorescence measurements and established the fragmentation patterns of BCl₃ at specific photon wavelengths (see Sec. 4.3).

2.1. Total Photoabsorption Cross Section, $\sigma_{pa,t}(\lambda)$

The vacuum UV absorption spectrum of BCl₃ (absorbance versus wave number) has been measured by Planckaert et al.⁵¹ from 200 to 120 nm. It has two well defined but broad bands with maxima near 57 970 cm^{-1} (7.187 eV, 173 nm) and 73 400 cm⁻¹ (9.100 eV, 136 nm). Planckaert et al. assigned the lowest frequency band to a valence-shell transition of the $\pi^* \leftarrow \pi$ type, and described the second band as a Rydberg transition to a 3s orbital or as a valence-shell transition of the $\sigma^* \leftarrow \sigma$ type. Another measurement of the relative photoabsorption cross section of BCl3 was made by Maria et al.⁵⁰ who reported a broad low-energy absorption band in the 200-220 nm region. Subsequently, Suto et al.44 measured the total photoabsorption cross section, $\sigma_{pa,t}(\lambda)$, of BCl₃ as a function of the photon wavelength λ in the 106– 190 nm range (Fig. 1). Suto et al. estimated the uncertainty in their measurements to be about $\pm 15\%$. According to Suto et al., the peak at 129 nm is likely to be due to the impurity HCl which could be produced by the reaction of BCl₃ with water adsorbed on the wall of their gas handling system. Another photoabsorption cross section measurement was made by Lee et al.⁴⁵ at shorter wavelengths (45-106 nm). These measurements have an uncertainty of $\pm 15\%$ and are also shown in Fig. 1.

Measurements of the photoabsorption cross section of BCl₃ at still higher energies (190–280 eV) have been made by Ishiguro *et al.*⁵³ using synchrotron light. Synchrotron light was similarly employed by Ueda *et al.*²⁷ for the measurement of Auger electron spectra. The latter have also been investigated by Cini *et al.*⁵⁴ using 2 keV electrons.

In Table 2 are listed vertical and adiabatic ionization energies for the BCl₃ molecule, along with corresponding suggested assignments.

2.2. Electron Affinity and Negative Ion States of BCl₃

As indicated earlier in this section, the three lowest unoccupied molecular orbitals of BCl₃ are $2a_2''$, $3a_1'$, and 4e'. These unoccupied molecular orbitals help explain the observed negative ion states of the BCl3 molecule and, consequently, the observed structure in the electron scattering and electron attachment cross sections. Table 3 lists values of the electron affinity and negative ion states of the BCl₃ molecule and the vertical detachment energy of BCl₃, as determined by various methods. The experimental data in Table 3 (see also Fig. 2) identify negative ion states of BCl₃ at about -0.3, 1.0, 2.8, 5.2, 7.6, and 9.0 eV. The -0.3 and 1.0 eV values are associated with the lowest empty orbital $2a_2''$, the 2.8 eV value with the $3a'_1$ empty orbital, and the 5.2 eV value with the 4e' empty orbital. The 7.6 and 9.0 eV values are associated with the positions of electron-excited Feshbach resonances in the 6.0-10 eV energy range.

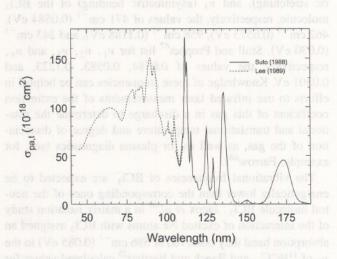


FIG. 1. Total photoabsorption cross section, $\sigma_{\text{pa,t}}(\lambda)$, for BCl₃: (----) Ref. 44; (---) Ref. 45.

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TABLE 2. Vertical and adiabatic^a ionization energies^b of BCl₃

| Ionization energy (eV) | Comment/ Orbital assignment | | Reference | Method |
|---------------------------|---|---------------------------------------|---|-----------------------|
| 10.9±0.2 | Threshold energy ^{c,d} for the production of | ground state BCl ⁺ | 55 | EI–MS ^e |
| 11.82 (11.60) | Values for the production of BCl_3^+ | | 42 | PES ^f |
| (11.60 ± 0.01) | Adiabatic value for the production of BC | | 43 | PI-MS ^g |
| $(11.16 - 11.44)^{h}$ | | Elastic differential electron scritte | 29 | C ⁱ |
| $(11.48 - 11.74)^{h}$ | Adiabatic values | | 29 | C |
| 11.49-11.83 ^h | Vertical values | | 29 | C |
| 11.68-12.34 ^h | Vertical values | | 20 | C |
| 11.60±0.02 | Threshold energy for the production of B | Cl_2^+ | 13 | PI-MS |
| 11.64 | Threshold energy for the production of B | | a second s | PAj |
| 11.67 ± 0.15 | Vertical value | | 45 56 | EI ^k |
| 11.72 | Vertical value, $1a_2^{\prime 1}$ | | 28 | He I EPS ^m |
| 11.73 (11.64) | $1a'_2; 2a'^n_2$ | | 41 | PES |
| 11.73 (11.64) | $\widetilde{X}^2 A'_2$ | | 46 | PA-SR ^o |
| 11.78 | | | 50 | C ^p |
| 11.82 (11.60) | $\widetilde{X}^{2a_2'}$, between the Statistical Statisticae Statisticae Statisticae | | 18 12 | PES |
| 11.97 | ergies for the BCL molecule , one with con | | | |
| 12.03±0.02 | "Appearance potential" for BCl_3^+ | | | 1.00 |
| 12.0±0.5 | "Appearance potential" for BCl_3^+ | | 60 | EI-MS EI-MS |
| 12.19 | | ~ | | DA |
| $12.214 (\nu=0)$ | Threshold energy for the production of B $1 e^{n/4}$ | | 45 00000 0000 | PA |
| 12.214 (12-0) | 2e'' | | 50 | He I EPS |
| 12.30 | Threshold energy for the production of B | ance measurements ino i +io | 58 45 | C ^p PA |
| 12.30±0.02 | Threshold energy for the production of B | | 43 | PA PI-MS |
| 12.39 (12.19) | $1e''$: $2e''^n$ | ci2 + ci+e | | |
| 12.39 (12.19) | \widetilde{A}^{1e} , $\widetilde{Z}^{e''}_{\widetilde{A}^{2}E''}$ and $\widetilde{Z}^{1e'}_{\widetilde{A}^{2}E''}$ | | | |
| 12.43 | | | | |
| 12.45 | 2 | | 19 49 59 w notong on | PES |
| | | | 48,42 | PES |
| | quentity, the observed structurer in the electro | | | |
| 12.608 (line 5) | electron attachment cross second attachment attache 3 i | | 28 | He I EPS |
| 12.66 | Threshold energy for the production of B | | | |
| 12.66 | $3e'; 7e'^n$ \tilde{P}^2E' | | | |
| 12.00 | DE | | | |
| 12.75 | $\widetilde{B}^{2}E'$ | | 48,42 | PES |
| | also Fig. 2) identity negative n_g on states o | | 59 00 | PES |
| 0.3 and 1.0 eV | | | | |
| | | | | |

2.3. Fundamental Vibrational Modes and Other Data

Herzberg⁶⁶ lists for the vibrational frequencies ν_1 (symmetric stretching), ν_2 (out-of-plane bending), ν_3 (asymmetric stretching), and ν_4 (asymmetric bending) of the BCl₃ molecule, respectively, the values of 471 cm⁻¹ (0.0584 eV), 462 cm⁻¹ (0.0573 eV), 958 cm⁻¹ (0.1188 eV), and 243 cm⁻¹ (0.030 eV). Stull and Prophet⁶⁷ list for ν_1 , ν_2 , ν_3 , and ν_4 , respectively, the values of 0.0584, 0.0583, 0.1223, and 0.0301 eV. Knowledge of these frequencies can be helpful in efforts to use infrared laser measurements of the extinction coefficient of this gas in a discharge to determine the rotational and translational temperature and degree of dissociation of the gas, as well as for plasma diagnostics (see, for example, Farrow⁶⁸).

The vibrational frequencies of BCl_3^- are expected to lie energetically lower than the corresponding ones of the neutral molecule BCl_3 . Jacox *et al.*⁶⁹ in a matrix isolation study of the interaction of excited Ne atoms with BCl_3 assigned an absorption band they observed at 686 cm⁻¹ (0.085 eV) to the ν_3 of ¹¹BCl_3^-, and Baeck and Bartlett²⁹ calculated values for all the vibrational frequencies of BCl_3^- . The averages of the two values they give for each frequency ν_1 , ν_2 , ν_3 , and ν_4 of BCl₃⁻ in Table VII of their paper are, respectively, 551 cm⁻¹ (0.068 eV), 320 cm⁻¹ (0.0397 eV), 704 cm⁻¹ (0.0873 eV), and 218 cm⁻¹ (0.0270 eV).

In Table 4 are listed other data on BCl_3 and BCl_3^- which are relevant to the present discussion on the interactions of slow electrons with the BCl_3 molecule.

3. Electron Scattering

3.1. Total Electron Scattering Cross Section, $\sigma_{\rm sc,t}(\epsilon)$

To our knowledge, there are no measured or calculated values of the total electron scattering cross section, $\sigma_{\rm sc,t}(\epsilon)$, of BCl₃.

3.2. Total Elastic Electron Scattering Cross Section, $\sigma_{\rm e,t}(\epsilon)$

There are no experimental measurements of the total elastic electron scattering cross section, $\sigma_{e,t}(\epsilon)$, of BCl₃. There are, however, a number of calculated values of the total (integral) elastic electron scattering cross section. Figure 3

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TABLE 2. Vertical and adiabatic^a ionization energies^b of BCl₃-Continued

| 14.10 | | $2a_2''$ note | | 58 | (Va) nontroop very C ^p |
|----------------------------------|------------------|-------------------------------|---|-------|-----------------------------------|
| 14.22 | Threshold energ | y for the production of | $\operatorname{BCl}_{3}^{+*}(\widetilde{C}^{2}A_{2}'')+e$ | 45 | PA |
| $14.240 (\nu_1^+=0)$ | | $1a_{2}^{''1}$ | | 28 | He I EPS |
| 14.40 (14.23) | | $\tilde{C}^2 A_2''$ | | 42 | PES |
| 14.41 (14.30) | | $\tilde{C}^2 A_2''$ | | 48 | PES |
| 14.42 (14.22) | | $1a_2''; 2a_2''^n$ | | 41 | PES |
| 14.42 (14.22) | | $\tilde{\tilde{C}}^2 A_2''$ | | 46 | PA-SR |
| 14.50 | | a" | | 59 | PES |
| 15.27 | | 6e' | | 58 | C ^p |
| 15.32 | Threshold energy | y for the production of | $\operatorname{BCl}_{3}^{+*}(\widetilde{D}^{2}E')+e$ | 45 | PA |
| 15.320 (progression 6, $\nu=0$) | | 2e' ¹ | Calculation | 28 | He I EPS |
| 15.51 (15.28) | | $\tilde{D}^{2}E''$ | | 42,48 | PES |
| 15.54 (15.32) | | 2e'; 6e' ⁿ | | 41 | PES |
| 15.54 (15.32) | | $\widetilde{D}^{\ 2}E''$ | | 46 | PA-SR |
| 15.75 | | e' | | 59 | PES |
| 17.74 (17.74) | Threshold energ | y for the production of | $EBCl_3^+ * (\tilde{E}^2 A_1') + e$ | 45,46 | PA, PA-SR |
| 17.74 | | 6a' | Calculation | 58 | $\mathbf{C}^{\mathbf{p}}$ |
| $17.699 (\nu_1^+ = 0)$ | | $2a_{1}^{'1}$ | | 28 | He I EPS |
| 17.70 (17.70) | | $\tilde{E}^{2}A_{1}^{\prime}$ | | 48,42 | PES |
| -(17.74) | | $2a'_1; 6a'^n_1$ | | 41 | PES |
| 17.79 | | a'_1 | | 59 | PES |
| 18.37 | Threshold ener | rgy for the production | of $BC1^+ + 2C1 + e$ | 45,43 | PA, PI-MS |

^aData in parenthesis are values designated by the corresponding authors as adiabatic.

^bSee Table 6 in Sec. 5 for electron impact values.

^cKoski *et al.*⁵⁵ measured the thresholds 11.0 ± 0.2 , 10.9 ± 0.2 , 10.9 ± 0.2 , and 10.6 ± 0.2 eV, respectively, for the production of B¹⁰Cl₂³⁷Cl³⁵⁺, B¹⁰Cl₂³⁵Cl³⁷⁺, B¹¹Cl₃³⁵⁺, and B¹⁰Cl₃³⁵⁺.

^dKoski *et al.*⁵⁵ measured mass spectrometrically the ionization threshold energies for the production of BCl_2^+ and BCl^+ by electron impact on BCl_3 and found them to be 7.20 and ~10.44 eV, respectively. Dibeler and Walker⁴³ estimated an ionization threshold for $BCl_2=7.74 \text{ eV}$ from photoionization studies. ^eEI-MS=electron impact-mass spectrometry.

| ^f PES=photoelectron spectroscopy. | |
|---|--|
| ^g PI-MS=photoionization-mass spectrometry. | |
| ^h The range of values corresponds to the results of various types of calculation. | |
| ⁱ C=calculation. To the other and day Ve CS 0 of no help in speedbars able with a Ve 0.0 | |
| ^j PA=photoabsorption. | |
| ^k EI=electron impact. | |
| ¹ Probable orbital. | |
| ^m He ₁ EPS=He ₁ excited photoelectron spectrum. | |
| ⁿ Assignments of Berger et al. ⁵⁷ based on their ab initio calculations. | |
| °PA-SR=photoabsorption-synchrotron radiation. | |
| | |

PAb initio calculation.

drift velocity data for BCI (Ar and BCI /He mixtures of Mostellar at of ¹⁴ Theorem and Inc. 7 The stress area

shows $\sigma_{e,t}(\epsilon)$ as calculated by a number of groups: Tossell *et al.*³⁰ using the multiple scattering $X\alpha$ method; Winstead and McKoy^{15,78} using the Schwinger multichannel variational method in the static exchange approximation with and without inclusion of polarization; Isaacs *et al.*⁶² using the complex Kohn method; and Bettega⁶³ using the Schwinger multichannel method with pseudopotentials at the static exchange polarization approximation. The inset in Fig. 3 shows an expanded view of the calculation of Isaacs *et al.* at low energies.

The contributions of the lowest unoccupied electronic states of BCl₃ to the magnitude and structure of $\sigma_{e,t}(\epsilon)$ shown in Fig. 3 can be seen from the calculated partial elastic electron scattering cross sections, $\sigma_{e,partial}(\epsilon)$, shown in Fig. 4. Figure 4(a) shows the $\sigma_{e,partial}(\epsilon)$ calculated by Tossell *et al.*³⁰ using the multiple scattering $X\alpha$ method. These results show the symmetry of the resonances which give rise to the peaks in the total elastic electron scattering cross section (see also Table 3). Figure 4(b) shows the polar-

ized self-consistent field (SCF) results of Isaacs *et al.*⁶² for the A_1 , A_2 , B_1 , and B_2 symmetries. The A_1 cross section is very large as the electron energy approaches zero and shows two broad maxima at 2.5 and 5.5 eV. Although the polarized-SCF B_2 cross section does not show a distinct peak due to the negative ion (shape) resonance near 2 eV, it does show this feature in the static exchange calculation results. Figure 4(c) shows the $\sigma_{e,nartial}(\epsilon)$ results of Bettega⁶³ to 50 eV.

nce,

3.3. Differential Elastic Electron Scattering Cross Section, $\sigma_{\rm e,diff}(\epsilon)$

Figure 5 shows the differential elastic electron scattering cross section, $\sigma_{e,diff}(\epsilon)$, of BCl₃ calculated by Isaacs *et al.*⁶² and Bettega⁶³ at several electron energies. Unfortunately, the

| Value/Energy position (eV) | 58 | Method of determine | nation 202 | Comment/Assignment | Reference |
|----------------------------|----|--|------------------------------|---|-------------------------|
| Electron affinity | | 2+(14, 2), (130 | nagy for the production of 1 | s protectu i | $4.240(16^{\circ} = 0)$ |
| 0.33 ± 0.2 | | Measurement ^a | | Adiabatic | 35 |
| 0.27 to 0.42 ^b | | Calculation | | Adiabatic | 35 29 |
| >0.0 | | Swarm measurements | | Formation of BCl ₃ | 61 |
| >0.0 | | Beam measurements | | Formation of BCl ₃ | 36,37 |
| Negative ion states | | | | | |
| ~0.9 | | Dissociative attachment prod | ucing Cl ⁻ | | 37 |
| 1.1 ± 0.1 | | Dissociative attachment prod | ucing Cl ⁻ | | 32 |
| <1.0 | | Electron transmission experir | | a "desid | 36,30 |
| 0.25 ^c | | Calculation | | B2 (0=4.0 | noiseange 62 |
| $0.41 - 0.79^{b}$ | | Calculation | | Vertical attachment energy | (85.8163 |
| 0.00-1.30 | | Calculation | | 0, | 64 |
| ~1.8 | | Calculation ^d | | B ₂ | 63 |
| ~2.6 | | Threshold-electron excitation | e | - | 32 |
| 2.86 | | Electron transmission experir | nent/Calculation | a' and a second | 36,30 |
| 2.5 | | Calculation ^f | | A | 62 |
| 5.16 | | Electron transmission experin | nent/Calculation | e' | 36,30 |
| 5.5 | | Calculation ^f | | $A_1; B_1$ | 62 |
| ~6.5 | | Dissociative attachment produ | ucing Cl ⁻ | | 37 |
| ~7.6 | | Threshold-electron excitation | e | | 32 |
| ~7.6 | | Electron transmission experir | nent/Calculation | Core-excited shape resonanceg | 36,30 |
| ~7.8 | | Dissociative attachment produ | ucing Cl ⁻ | La concentra i | 37 |
| 8.7 | | SF ₆ ⁻ scavenger technique | oding autiens as adjubatio. | | 32 |
| 9.05 | | Electron transmission experir | nent/Calculation | Core-excited shape resonance ^g | 30,36 |
| 9.7 048 540 044 | | Threshold-electron excitation | 0.2, 10.9±0.2, and 10.6±0 | ured the thresholds 11.0±0.2, 10.9± | 32 |
| 8.5 | | Calculation ^d | | A_1, B_1 | 62 |
| Vertical detachment energy | | | | | |
| 1.77 uta noitasinoiolorio | | Optogalvanic experiments | | | 65 |
| 1.73-1.99 ^b | | Calculation | | | 29 |

TABLE 3. Electron affinity and negative ion states of BCl₃ and vertical detachment energy of BCl₃

^aDetermined using collisions of Cs atoms with BCl₃.

^bThe range of values corresponds to the results of various types of calculation. ^cThe position of this B_2 symmetry shape resonance moves from ~2.0 eV in the static exchange calculation to 0.25 eV with the inclusion of polarization effects (see Isaacs *et al.*⁶²). ^dStatic exchange approximation calculation. ^eSF₆⁻ scavenger technique. ^fPolarized-SCF calculations. ^gObserved in electron transmission and in dissociative electron attachment experiments.

results of these two calculations can be compared at only one common energy (5.0 eV). There are no experimental measurements of $\sigma_{e,diff}(\epsilon)$ for this molecule.

3.4. Momentum Transfer (Elastic) Cross Section,

```
\sigma_{\rm m}(\epsilon)
Figure 6 shows the elastic momentum transfer cross section, \sigma_{\rm m}(\epsilon), of BCl<sub>3</sub> as calculated by McKoy and associates,<sup>15,78</sup> Isaacs et al.,<sup>62</sup> and Bettega.<sup>63</sup> The inset in Fig. 6 is an expansion of the results of Isaacs et al.,<sup>62</sup> showing the
```

3.5. Inelastic Electron Scattering Cross Sections,

 $\sigma_{\sf in}(\epsilon)$ 3.5.1. Vibrational Excitation Cross Sections

Nagpal and Garscadden⁷² derived three vibrational excitation cross sections for BCl_3 in the energy range 0–30 eV using the conventional "two-term" solution of the timedependent Boltzmann transport equation and the electron

 B_2 resonance.

drift velocity data for BCl₃/Ar and BCl₃/He mixtures of Mosteller *et al.*¹⁴ These are shown in Fig. 7. The cross sections designated by $\sigma_{\nu 2,\nu 1}$, $\sigma_{\nu 4}$, and $\sigma_{\nu 3}$ are for the vibrational frequencies indicated by the subscripts. McKoy *et al.*⁷⁸ questioned these data on the basis that they are based on experimental measurements taken under conditions for which electron attachment is significant and this was not considered in the analysis.

3.5.2. Electronic Excitation Cross Sections

Cross sections for some electronic transitions of BCl_3 (and also of the BCl and BCl_2 fragments) have been computed by McKoy *et al.*¹⁵

3.5.3. Cross Sections for Dissociation into Neutral Fragments

Using the same experimental data and computational procedure as for the vibrational excitation cross sections (Fig. 7), Nagpal and Garscadden⁷² derived two dissociation cross sections for BCl₃. These are shown in Fig. 7 and are designated by σ_{d1} and σ_{d2} . They refer, respectively, to the disso-



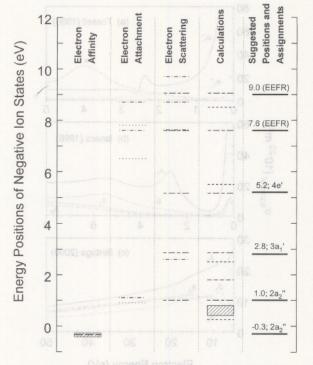


FIG. 2. Negative ion states of the BCl₃ molecule as determined by electron affinity measurements, electron attachment measurements, electron scattering measurements, and calculations: Electron affinity: (- - -) experimental data from Ref. 35, (///) calculations from Ref. 29; Dissociative electron attachment producing Cl⁻: experimental data from (\cdots) Ref. 37 and (- - - -) Ref. 32; Electron scattering: experimental data from (- - -) Refs. 36, 30 and (- - - -) Ref. 32; Electron scattering: calculated results from (- - -) Ref. 62, (///) Ref. 29, (- - -) Ref. 63, and (- - -) Ref. 30. The last column gives the suggested positions and assignments. It should be noted that the adiabatic position of the \sim 1.0 eV negative ion state is at about -0.3 eV $[-|EA(BCl_3)|]$. EEFR labels refer to assignments made from electron excited Feshbach resonance data.

 Dissociation of BCI₃ by Electron and Photon Imnact

ciation processes leading to BCl_2+Cl and $BCl+Cl_2$ (see values of the energy thresholds for these processes in Table 4). In Fig. 7 is also plotted an estimate of the electron-impact dissociation cross section as computed by McKoy *et al.*¹⁵ This latter cross section is essentially the sum of the cross sections they computed for electronic states presumed to be dissociative. In this regard, the estimated cross section by McKoy *et al.* for dissociation of BCl₃ into neutrals should at best be a lower limit value.

The cross sections of Nagpal and Garscadden⁷² are observed to have a lower magnitude and to lie at lower energies than the cross sections of McKoy *et al.*¹⁵ This has been attributed¹⁵ to the neglect of the effect of electron attachment in the calculation of Nagpal and Garscadden, and to the fact that the dissociation energies are larger than the threshold values used by Nagpal and Garscadden.

4. Electron Impact Ionization

4.1. Partial Ionization Cross Sections, $\sigma_{i,partial}(\epsilon)$

An early electron-impact ionization study of BCl₃ by Marriott and Craggs³¹ showed that the most abundant positive TABLE 4. Other basic properties of BCl₃ and BCl₃

| Value Re | eference |
|---|--|
| | |
| 1.754 Å, 1.755 Å | 29 |
| 1.754 Å | 62 |
| 1.751 Å ^a | 70 |
| 1.75 Å 02 | 67 |
| 1.745 Å ^b | 71 |
| 1.742 Å | 63 |
| 1.742 Å | 30 |
| | |
| 4.78±0.02 eV | 43 |
| ~4.59 eV | 61 |
| 4.61 eV | 72 |
| 5.65 eV | 72 |
| 3.39±0.02 eV | 43 |
| 5.51±0.04 eV | 43 |
| $9.6 \times 10^{-24} \mathrm{cm}^3$ | 12 |
| $9.47 \times 10^{-24} \mathrm{cm}^3$ | 73 |
| $9.38 \times 10^{-24} \text{ cm}^3$ | 73 |
| $8.99 \times 10^{-24} \text{ cm}^{3c}$ | 74 |
| $8.21 \times 10^{-24} \mathrm{cm}^{3d}$ | 75 |
| | |
| 120° | 67 |
| | |
| 1.876 Å, 1.879 Å ^e | 29 |
| | |
| | |
| 107 20 107 600 | 20 |
| 110.9° ^f | 76 |
| | 1.754 Å 1.754 Å 1.754 Å 1.751 Å ^a 1.755 Å 1.742 Å 1.742 Å 1.742 Å 4.78 \pm 0.02 eV ~4.59 eV 4.61 eV 5.65 eV 3.39 \pm 0.02 eV 5.51 \pm 0.04 eV 9.6 \times 10 ⁻²⁴ cm ³ 9.47 \times 10 ⁻²⁴ cm ³ 8.99 \times 10 ⁻²⁴ cm ³ 8.99 \times 10 ⁻²⁴ cm ³ 8.21 \times 10 ⁻²⁴ cm ³ 120° 1.876 Å, 1.879 Å ^e 1.836 Å ^f |

Ab initio calculations.

^fDetermined from studies of the molecular structure of donor-acceptor complexes of trimethylamine and boron trichloride.

^gThe BCl₂ radical is bent with a CIBCl angle of $\sim 122^{\circ}$ (see Franzi *et al.*⁷⁷).

TO SURFICIENCE .

ion is BCl_2^+ , followed by BCl_3^+ . Subsequently, in a mass spectrometric study of the photoionization of BCl_3 , Diebeler and Walker⁴³ found that the relative abundances of the positive ions BCl_3^+ , BCl_2^+ , BCl^+ , and B^+ at 584 Å (21.23 eV) are: 0.59, 1.0, 0.072, and ~0.001. A more recent study of the fragmentation of valence electronic states of BCl_3^+ using photoelectron spectroscopy by Biehl *et al.*⁴² found that between 11 and 19 eV the BCl_2^+ ion is produced from the fragmentation of the excited states of BCl_3^+ .

The most detailed study of electron-impact ionization of BCl₃ was conducted by Jiao *et al.*³³ using Fourier transform mass spectrometry. They observed the formation of the parent positive ion BCl₃⁺ and the fragment positive ions BCl₂⁺, BCl⁺, and Cl⁺. The positive-ion fragments BCl⁺ and Cl⁺ were found to react with neutral BCl₃ to generate BCl₂⁺ with bimolecular rate constants respectively equal to $(5.3\pm0.5) \times 10^{-10}$ cm³ s⁻¹ and $(6.2\pm0.5) \times 10^{-10}$ cm³ s⁻¹. The BCl₂⁺ ion was found not to react with BCl₃. Jiao *et al.*³³ did not observe B⁺ or Cl₂⁺, thus confirming the suspicion of Marriott and Craggs³¹ that the observation of these two positive ions in their experiment was an artifact of pyrolysis on the filament. Table 5 lists the threshold energies ("appearance

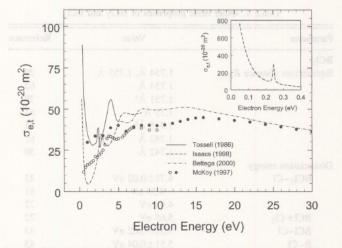


FIG. 3. Calculated total (integral) elastic electron scattering cross section, $\sigma_{e,l}(\epsilon)$, for BCl₃: (—) Ref. 30; (**•**) Ref. 15 static-exchange approximation without polarization; (\bigcirc) Ref. 15 static-exchange approximation with polarization; (---) Ref. 62; ($-\cdot - \cdot - \cdot -$) Ref. 63. (Inset) Low energy data of Isaacs *et al.*

potentials") of the various positive ions produced by electron impact on BCl₃.

Jiao *et al.*³³ measured the partial ionization cross sections, $\sigma_{i,partial}(\epsilon)$, of BCl₃ relative to the ionization cross section of argon and calibrated their data using the measurements of Wetzel *et al.*⁸⁰ and Krishnakumar and Srivastava⁸¹ for Ar. They gave no uncertainty for the magnitude of $\sigma_{i,partial}(\epsilon)$, but the uncertainty in their energy scale was quoted as ± 0.5 eV. Their data for $\sigma_{i,partial}(\epsilon)$ are shown in Fig. 8 and are listed in Table 6. The cross section for BCl₃⁺ is seen to be substantial. Interestingly, Overzet and Luo⁸² in a study of ionization in rf plasmas of pure BCl₃ observed only the positive ions BCl₂⁺, BCl⁺, and B⁺. The data of Jiao *et al.* show that from threshold to 60 eV the most abundant positive ion is BCl₂⁺.

4.2. Total Ionization Cross Section, $\sigma_{i,t}(\epsilon)$

The sum of the partial ionization cross sections of Jiao et al.³³ for BCl₃⁺, BCl₂⁺, BCl⁺, and Cl⁺ has been plotted in Fig. 9 and is taken to represent the total ionization cross section, $\sigma_{i,t}(\epsilon)$, of BCl₃. Values of these data for electron energies ≤30 eV are listed in Table 7. These data represent our suggested values, but they should be considered a lower limit to $\sigma_{i,t}(\epsilon)$. To our knowledge there are no other measurements of $\sigma_{i,t}(\epsilon)$. According to Becker⁸³ the preliminary measurements by Tarnovsky and Becker quoted in Deutsch et al.⁸⁴ need further scrutiny. In Fig. 9 the measurements of Jiao et al. are compared with the calculated values obtained using the modified additivity-rule (MAR),^{84,85} the Deutsch-Märk (DM) formalism,85 and the binary encounter-Bethe (BEB) theory.⁸⁶ Below 30 eV, the latter calculation gives $\sigma_{ii}(\epsilon)$ values in better overall agreement with the experimental results of Jiao et al., thus the results of this calcula-

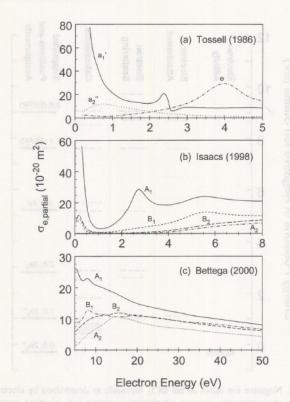


FIG. 4. Calculated partial elastic electron scattering cross sections, $\sigma_{e, partial}(\epsilon)$, for BCl₃ for the identified symmetries: (a) Ref. 30; (b) Ref. 62; (c) Ref. 63.

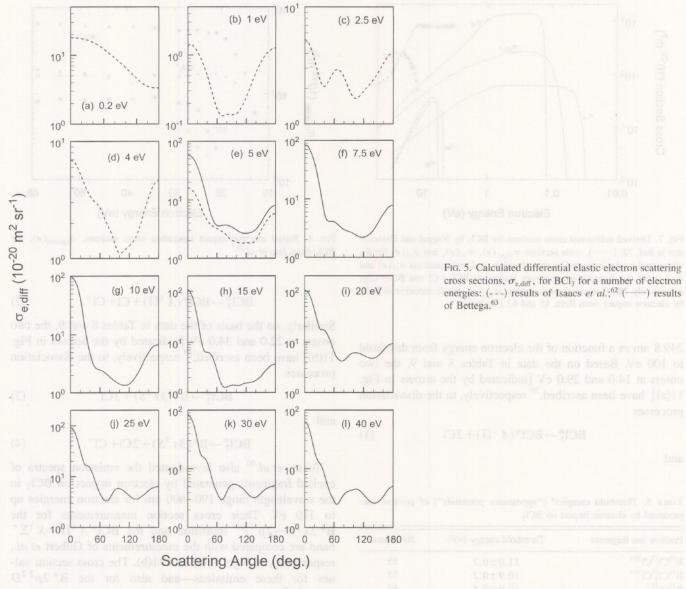
tion may be also preferred above ~ 30 eV. However, significant discrepancies exist among the available data and the need for more investigation is evident.

4.3. Dissociation of BCl₃ by Electron and Photon Impact

Besides the calculated results discussed in Sec. 3.5.3, there are no measurements of the cross section for electron-impact dissociation of BCl₃ into neutral fragments. However, there have been a number of studies on electron-impact-induced dissociation^{38–40,87} and photon-impact-induced dissociation^{44–49} of BCl₃ and identification of the resultant (excited) radicals via their fluorescence emissions. The results of these electron-impact and photon-impact studies are briefly elaborated upon in this section, since they provide useful spectroscopic data for the identification of the species in plasma reactors containing BCl₃.

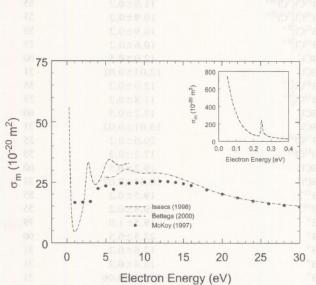
Jabbour *et al.*³⁸ measured the absolute photoemission cross section of the BCl* $A^{1}\Pi \rightarrow X^{1}\Sigma^{+}$ system around 2720 Å produced by dissociative electron impact on BCl₃. This system is used for optical plasma diagnostics. The cross section was found to rise from the threshold at 14.0±1.5 eV to a maximum near 25 eV and then to rise again to its overall maximum at near 40 eV. The maximum cross section value was measured to be 2.3×10^{-18} cm² with an uncertainty of ±20%. In a subsequent study, Gilbert *et al.*³⁹ reported photoemission cross sections and appearance potentials for the most intense UV emissions produced by electron-impact dis-

INTERACTIONS WITH BCI3



sociation of BCl₃. In particular, Gilbert et al.³⁹ studied the two atomic boron emissions $B^* 2p^{2\,2}D \rightarrow 2p^{\,2}P^0$ line at 208.9 nm and B* 3s ${}^2S \rightarrow 2p {}^2P^0$ line at 249.8 nm, and the BCl* $A^{1}\Pi \rightarrow X^{1}\Sigma^{+}$ system around 272.4 nm. The 249.8 nm boron line was found to have the largest emission cross section $(5.4 \times 10^{-18} \text{ cm}^2)$ at 75 eV. The BClA ${}^1\Pi \rightarrow X {}^1\Sigma^+$ emission cross section around 272.4 nm was found to be 3 $\times 10^{-18}$ cm² at 40 eV, which is $\sim 20\%$ higher than their earlier measurement.³⁸ Figure 10 shows the emission spectrum recorded by Gilbert et al.³⁹ in the wavelength range 200-300 nm, generated by impact of 200 eV electrons on BCl₃. The two B* lines at 208.9 and 249.8 nm and the BCl* $A^{1}\Pi$ $\rightarrow X^{1}\Sigma^{+}$ emission band around 272.4 nm are clearly seen in the figure. The radiative lifetime of the BCI* A state [for the spectrally unresolved (0,0), (1,1) and (2,2) bands at 272 nm] was measured by Hesser⁸⁷ to be 19.1 ns.

Figures 11(a) and 11(b) give, respectively, the emission cross sections measured by Gilbert *et al.*³⁹ for the BCI* $A^{1}\Pi \rightarrow X^{1}\Sigma^{+}$ band and the B* $3s^{2}S \rightarrow 2p^{2}P^{0}$ line at



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FIG. 6. Calculated elastic momentum transfer cross section, $\sigma_{\rm m}(\epsilon)$, for BCl₃: (•) static-exchange approximation result from Ref. 15; (---) Ref. 62; (----) Ref. 63. (Inset) Expanded results by Isaacs *et al.* from Ref. 62 showing the B_2 resonance.

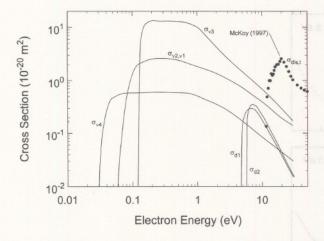


FIG. 7. Derived collisional cross sections for BCl₃ by Nagpal and Garscadden in Ref. 72: (----), cross sections $\sigma_{\nu_2,\nu_1}(\epsilon)$, $\sigma_{\nu_4}(\epsilon)$, and $\sigma_{\nu_3}(\epsilon)$ for the vibrational modes indicated by the subscripts, and cross sections $\sigma_{d_1}(\epsilon)$ and $\sigma_{d_2}(\epsilon)$ for the dissociation processes leading to BCl₂+Cl and BCl+Cl₂, respectively. (•) Computed cross section, $\sigma_{dis,l}(\epsilon)$, for dissociation of BCl₃ by electron impact from Refs. 15 and 62 (see text).

249.8 nm as a function of the electron energy from threshold to 100 eV. Based on the data in Tables 8 and 9, the two onsets at 14.0 and 29.0 eV [indicated by the arrows in Fig. 11(a)], have been ascribed,³⁹ respectively, to the dissociation processes

$$BCl_{3}^{*} \rightarrow BCl^{*}(A^{1}\Pi) + 2Cl \qquad (1)$$

and

produced by electron impact on BCL

TABLE 5. Threshold energies^a ("appearance potentials") of positive ions

| Positive ion fragment | Threshold energy (eV) | Reference |
|---|----------------------------------|-----------|
| B ¹⁰ Cl ₂ ³⁷ Cl ³⁵⁺ | 11.0 ± 0.2 | 55 |
| $B^{10}Cl_2^{35}Cl^{37+}$ | 10.9 ± 0.2 | 55 |
| $B^{11}Cl_3^{\bar{3}5+}$ | 10.9 ± 0.2 | 55 |
| $B^{10}Cl_{3}^{35+}$ | 10.6 ± 0.2 | 55 |
| BCl ⁺ | 12.0 ± 0.5 | 60 |
| BCl ⁺ | 12.03 ± 0.02 | 31 |
| $B^{10}Cl_2^{37+}$ | 12.0 ± 0.2 | 55 |
| $B^{11}Cl_{2}^{35+}$ | 11.8 ± 0.2 | 55 |
| BCl ⁺ | 13.2 ± 0.5 | 60 |
| BC1 ⁺ | 13.01 ± 0.02 | 31 |
| B ¹⁰ Cl ³⁵⁺ | 20.0 ± 0.2 | 55 |
| B ¹¹ Cl ³⁵⁺ | 17.2 ± 0.2 | 55 |
| BC1 ⁺ | 19.2 ± 0.5 | 60 |
| BC1 ⁺ | 18.54 ± 0.07 | 31 |
| B ¹¹⁺ | 19.5 ± 0.2 | 55 |
| B ¹⁰⁺ | 20.8 ± 0.2 | 55 |
| B ⁺ | 19.5 ± 1.0 | 79 |
| B ⁺ | 22.5 ± 0.5 | 60 |
| B ⁺ | 13.6 ± 0.2 | 31 |
| 20 25 30 ⁺ B | 13.0 ± 0.2 18.4 ± 0.2 | 31 |
| | 22.35 ± 0.06 | 31 |
| Cl ⁺ | 12.9 ± 0.15 | 31 |
| Cl ⁺ .(a), a .noirose roor | 17.1 ± 0.15 | 31 |
| | 12.03 ± 0.05 | |
| | 33.77±0.07 | |

^aSee also Table 2.

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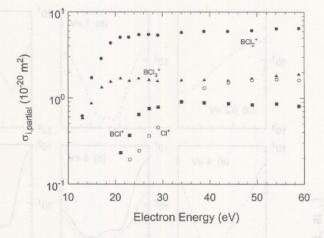


FIG. 8. Partial electron-impact ionization cross sections, $\sigma_{i,partial}(\epsilon)$, for BCl₃ from Jiao *et al.*³³

$$\mathrm{BCl}_{3}^{*} \rightarrow \mathrm{BCl}^{*}(A^{1}\Pi) + \mathrm{Cl} + \mathrm{Cl}^{+}.$$
 (2)

Similarly, on the basis of the data in Tables 8 and 9, the two onsets at 22.0 and 34.0 eV [indicated by the arrows in Fig. 11(b)] have been ascribed,³⁹ respectively, to the dissociation processes

$$BCl_3^* \to B^*(3s^2S) + 3Cl \tag{3}$$

$$\operatorname{BCl}_{3}^{*} \to \operatorname{B}^{*}(3s^{2}S) + 2\operatorname{Cl} + \operatorname{Cl}^{+}.$$
(4)

Tokue *et al.*⁴⁰ also investigated the emission spectra of excited fragments generated by electron impact on BCl₃ in the wavelength range 190–600 nm for electron energies up to 110 eV. Their cross section measurements for the B* $3s^2S \rightarrow 2p^2P^0$ transition and the BCl* $A^{-1}\Pi \rightarrow X^{-1}\Sigma^{+}$ band are compared with the measurements of Gilbert *et al.*, respectively, in Figs. 11(a) and 11(b). The cross section values for these emissions—and also for the B* $2p^{2}D \rightarrow 2p^{-2}P^{0}$ transition—are compared in Table 10 for 100 eV electrons. Although the cross section value of Gilbert *et al.* for the transition B* $2p^{2}D \rightarrow 2p^{-2}P^{0}$ is about a factor of 2 lower than that of Tokue *et al.*, the agreement between the measurements of the two groups is generally good. In addi-

TABLE 6. Suggested partial ionization cross sections, $\sigma_{i,partial}(\epsilon)$, for BCl₃ (data digitized from figure of Jiao *et al.*³³)

| Electron energy (eV) | $\sigma_{\mathrm{i,partial}}(\epsilon) \ (10^{-20} \mathrm{m}^2)$ | | | | |
|-------------------------|---|-------------------------------|------------------|-----------------|--|
| | BCl ₂ ⁺ | BCl ₃ ⁺ | BC1 ⁺ | Cl ⁺ | |
| 13.0 | 0.6 | 0.6 | lines at 208.9 | *a ow | |
| 15.0 | 1.7 | 0.9 | | | |
| 17.0 | 2.9 | 1.3 | | | |
| 19.0 | 4.4 | 1.6 | | | |
| 21.0 | 5.1 | 1.7 | 0.2 | | |
| 23.0 | 5.1 | 1.6 | 0.4 | 0.2 | |
| 25.0 | 5.5 | 1.7 | 0.6 | 0.2 | |
| 27.0 | 5.5 | 1.6 | 0.8 | 0.4 | |
| 29.0 | 5.4 | 1.6 | 0.8 | 0.5 | |

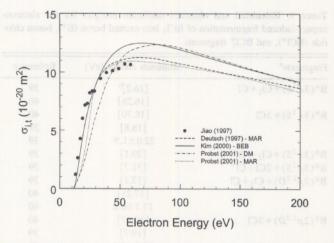


FIG. 9. Total ionization cross section, $\sigma_{i,t}(\epsilon)$, for BCl₃: (•) experimental values (sum of the partial ionization cross sections in Fig. 8 and Table 7) from Ref. 33; (- - -) calculated values/MAR from Ref. 84); (---) calculated values/MAR from Ref. 84); (---) calculated values/DM from Ref. 85; (···) calculated values/MAR from Ref. 85.

tion to the emissions from the three species just mentioned, Tokue *et al.*⁴⁰ observed two continuous emissions in the wavelength regions 230–380 nm and 400–580 nm which they attributed to BCl^{*}₂.

Figure 12(a) shows the fluorescence cross section, and Fig. 12(b) the fluorescence quantum yield, of BCl₃ in the wavelength range 106–190 nm as measured by Suto *et al.*⁴⁴ using synchrotron light. The fluorescence cross section measurements have a quoted uncertainty of $\pm 30\%$. They indicate a fluorescence threshold of ~173 nm (7.17 eV) and a number of emission bands in the VIS and the UV regions attributed by Suto *et al.* to excited states of the BCl₂ photofragment. The fluorescence quantum yield was calculated from the ratio of the fluorescence and absorption cross sections [see Figs. 12(a) and 1]. It shows three broad bands with peaks near 118, 130, and 142 nm, which indicate that the dissociating states have, respectively, vertical excitation energies of 10.5, 9.5, and 8.7 eV.

Lee *et al.*⁴⁵ extended these room-temperature investigations to excitation wavelengths in the region 45-106 nm. Their fluorescence data are also shown in Figs. 12(a) and 12(b) and have a quoted uncertainty of $\pm 30\%$. The observed

TABLE 7. Suggested total ionization cross sections, $\sigma_{i,t}(\epsilon)$, for BCl₃ for electron energies less than 30 eV (data digitized from figure of Jiao *et al.*³³)

| Electron energy (eV) | $\sigma_{\mathrm{i},\mathrm{t}}(\epsilon) \ (10^{-20}\mathrm{m}^2)$ |
|---------------------------|---|
| 13.0 | 1.2 |
| 15.0 | 2.6 |
| 20184020 m 15.0 17.0 | 1.2 2.6 4.2 |
| 19.0 | 6.0 |
| 21.0 21.0 | (A) OR bo7.0 to notice |
| AAADA to 23.0 ptrim not a | 108 10 007.3 000 108000 |
| 24.0 | |
| 27.0 | |
| 29.0 | 8.3 8.3 |

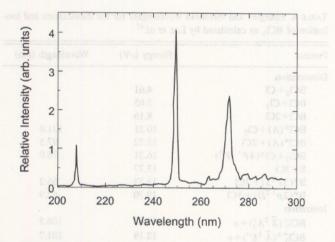


FIG. 10. Emission spectrum between 200 and 300 nm induced by impact of 200 eV electrons on BCl₃ (see text) from Ref. 39.

emissions at excitation wavelengths longer than 96 nm were attributed to BCl₂^{*} and those at excitation wavelengths shorter than 97.5 nm to BCl*(A-X).⁴⁵ Emissions at the thresholds of 88 and 81 nm were attributed to BCl₃^{+*} and emissions appearing in the 48–64 nm region to B* atoms.

Synchrotron light was also used by Boyle *et al.*⁴⁹ to study the fluorescence processes in BCl₃ following vacuum UV (VUV) photoexcitation of BCl₃ in the energy range 9-(137.7 nm) to 22 eV (56.4 nm). Photoexcitation of BCl₃ in this energy range resulted in complicated fluorescence spectra in which the observed emissions were assigned to BCl²₇, BCl^{*},

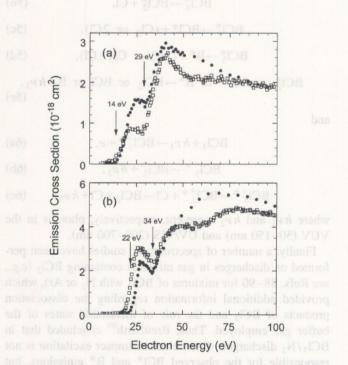


FIG. 11. (a) Emission cross section for the BCl* $A^{1}\Pi \rightarrow X^{1}\Sigma^{+}$ band as a function of the electron energy: (**●**) Gilbert *et al.*³⁹ (**□**) Tokue *et al.*⁴⁰ (b) Emission cross section for the transition B* $2s^{2}S \rightarrow 2p^{2}P^{0}$ as a function of the electron energy: (**●**) Gilbert *et al.*³⁹ (**□**) Tokue *et al.*⁴⁰

TABLE 8. Energies and threshold wavelengths for the dissociation and ionization of BCl₃ as calculated by Lee *et al.*⁴⁵

| Process | Energy (eV) | Wavelength (nm) | |
|---|-------------|-----------------|--|
| Dissociation | | (arts | |
| $BCl_2 + Cl$ | 4.61 | | |
| BCl+Cl ₂ | 5.65 | | |
| BC1+2C1 | 8.16 | | |
| $BCl^*(A) + Cl_2$ | 10.21 | 121.4 | |
| $BCl^*(A) + 2Cl$ | 12.72 | 97.5 | |
| $BCl_2 + Cl^* (4P'^2 P^0)$ | 16.31 | 76.0 | |
| B+3Cl | 13.77 | | |
| $B^*(3s^2S) + 3Cl$ | 18.73 | 66.2 | |
| $B^*(2p^{2} D) + 3Cl$ | 19.70 | 62.9 | |
| Ionization | | | |
| $\mathrm{BCl}_3^+(\widetilde{X}^2A_2') + e$ | 11.64 | 106.5 | |
| $\mathrm{BCl}_{3}^{+*}(\widetilde{A}^{2}\widetilde{E}'')+e$ | 12.19 | 101.7 | |
| BCl ⁺ + Cl scabal an OOE | 12.30 | | |
| $\operatorname{BCl}_{3}^{+}(\widetilde{B}^{2}E')+e$ | 12.66 | 97.9 | |
| $\operatorname{BCl}_{3}^{+*}(\widetilde{C}^{2}A_{2}'')+e$ | 14.22 | 87.2 | |
| $\mathrm{BCl}_{3}^{+*}(\widetilde{D}^{2}E')+e$ | 15.32 | 80.9 | |
| $\operatorname{BCl}_{3}^{+*}(\widetilde{E}^{2}A_{1}')+e$ | 17.74 | 69.9 | |
| $BCl^+ + 2Cl + e$ | 18.37 | | |

 BCl_3^{+*} , BCl_2^{+*} , and B^* . As the authors noted, their experiments are sensitive to those Rydberg states of BCl_3 which photodissociate to an excited state of a neutral fragment that fluoresces, and to valence states of the parent or a fragment ion that fluoresce. These two processes can be represented as⁴⁹

$$BCl_{2} + h\nu_{1} \rightarrow BCl_{*}^{*}$$
(5a)

$$BCl_3^* \to BCl_2^* + Cl, \tag{5b}$$

 $BCl_3^* \rightarrow BCl^* + (Cl_2 \text{ or } 2Cl),$ (5c)

$$BCl_3^* \rightarrow B^* + (3Cl \text{ or } Cl_2 + Cl), \qquad (5d)$$

$$BCl_2^*$$
 or BCl^* or $B^* \rightarrow BCl_2$ or BCl or $B+h\nu_2$,
(5e)

and

$$\mathrm{BCl}_3 + h\nu_1 \to \mathrm{BCl}_3^{+*} + e, \tag{6a}$$

$$\mathrm{BCl}_{3}^{+*} \to \mathrm{BCl}_{3}^{+} + h \nu_{2}, \qquad (6b)$$

$$\mathrm{BCl}_{3}^{+*} \rightarrow \mathrm{BCl}_{2}^{+*} + \mathrm{Cl} \rightarrow \mathrm{BCl}_{2} + \mathrm{Cl} + h\nu_{2}, \qquad (6c)$$

where $h\nu_1$ and $h\nu_2$ represent, respectively, photons in the VUV (50–150 nm) and UV/VIS (200–700 nm).

Finally, a number of spectroscopic studies have been performed on discharges in gas mixtures containing BCl₃ (e.g., see Refs. 88–90 for mixtures of BCl₃ with N₂ or Ar), which provided additional information regarding the dissociation products of BCl₃ and the role of metastable states of the buffer gas employed. Thus, Breitbarth⁸⁸ concluded that in BCl₃/N₂ discharges, direct electron-impact excitation is not responsible for the observed BCl* and B* emissions, but rather an energy transfer from the N₂^{*}(W) state to the BCl_x species present in his system. In the case of BCl₃/Ar discharges, Scheller *et al.*⁸⁹ argued that argon metastables indiTABLE 9. Calculated and observed minimum energies for the electronimpact-induced fragmentation of BCl_3 into excited boron (B*), boron chloride (BCl*), and BCl_2^* fragments

| Fragments ^a | Minimum energy (eV) | Reference | |
|---|--------------------------|-----------|--|
| $B^*(3s^2S) + Cl_2 + Cl$ | [16.2] ^b | 39 | |
| | [16.28] | 40 | |
| $B^*(3s^2S) + 3Cl$ | [18.70] | 40 | |
| | [18.8] | 39 | |
| | 22.0±1.5° | 39 | |
| $B^*(3s^2S) + Cl_2 + Cl^+$ | [29.1] | 39 | |
| $B^*(3s^2S) + 2C1 + C1^+$ | [31.7] | 39 | |
| $B^{*}(2p^{2} D) + Cl_{2} + Cl$ | [17.1] | 39 | |
| | [17.25] | 40 | |
| | 17.7±0.2 | 40 | |
| $B^{*}(2p^{2} D) + 3Cl$ | non [19.67] | 40 | |
| | [19.7] | 39 | |
| | 20.0±0.5 | 40 | |
| $B^*(2p^{2}D) + Cl_2 + Cl^+$ | [30.0] | 39 | |
| | [30.28] | 40 | |
| $B^*(2p^{2}D) + 2Cl + Cl^+$ | [32.6] | 39 | |
| | [32.70] | 40 | |
| $B^*(3p^2P^0) + Cl_2 + Cl$ | [17.34] | 40 | |
| | 17.7 ± 0.4 | 40 | |
| $B^*(3p\ ^2P^0) + 3Cl$ | [19.76] | 40 | |
| | 19.7±0.3 | 40 | |
| $D(Sp r) + Cl_2 + Cl$ | [30.37] | 40 | |
| $B^*(3p^2P^0) + 2Cl + Cl^+$ | [32.79] | 40 | |
| $BCl^*(A^{1}\Pi) + Cl_2$ | [10.50] | 39,40 | |
| $BCl^*(A^{-1}\Pi) + 2Cl$ | [13.1] | 39 | |
| | [12.92] | 40 | |
| | 13.9±0.5 | 40 | |
| | 14.0=1.0 | 33 | |
| $\mathrm{BCl}^*(A^{-1}\Pi) + \mathrm{Cl} + \mathrm{Cl}^+$ | [26.0] | 39 | |
| | | 40 | |
| | 25-29 | 40 | |
| | 20.0.1.2.0 | 39 | |
| $BCl_{2}^{*}(468 \text{ nm}) + Cl$ | [6.75] | 40 | |
| | 7.0±0.6 | 40 | |
| | ony ration 7,17 0100/200 | 44 | |
| BCl [*] ₂ (330 nm) + Cl | [8.90] of [8.90] | 40 | |
| wee broad bands with | | 40 | |
| | 0.8.0 | 44 | |

^aExcited fragments are designated by the asterisk (*).

^bValues in brackets are calculated by the respective authors using the enthalpies of formation for the parent molecule, the related fragments, and electronic energies of the excited states involved (see respective references for details). ^cValues not in brackets are measurements.

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rectly enhance molecular dissociation by increasing the positive ion density via Penning ionization (that is, especially at concentrations below 5%, Penning ionization generates BCl_3^+ which subsequently undergoes dissociative recombination). Similarly, Breitbarth and Ducke⁹⁰ observed three broad emissions with maxima at 305, 350, and 480 nm in rf discharges using pure BCl_3 . They attributed all three emissions to the electronically excited BCl_2^* fragment. In discharges with pure BCl_3 , they showed the dominant process for formation of excited $BCl^*(A)$ fragments to be direct electronimpact excitation of BCl(X). For mixtures of BCl_3/Ar , however, the $BCl^*(A^{-1}\Pi)$ species are also produced via energy transfer from argon metastables.

It should perhaps be mentioned that a number of other

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TABLE 10. Absolute cross sections of boron and boron chloride fragment emissions formed by 100 eV electrons impacting on BCl₃, and associated wavelengths, transitions, and measured onsets

| Fragment | Wavelength (nm) | Transition | Cross section (10^{-18} cm^2) | Onset energy (eV) | Reference |
|----------------|--------------------|--|---|----------------------|-----------|
| Boron | 208.9 | $2p^2 {}^2D \rightarrow 2p {}^2P^0$ | 1.8±0.9 ^a | 23.0±1.5 | 39 |
| | | | | 34.5 ± 2.0 | 39 |
| | 208.9 | $2p^2 {}^2D \rightarrow 2p {}^2P^0$ | 4.9±1.0 | | 40 |
| Boron | 249.8 | $3s^2S \rightarrow 2p^2P^0$ | 4.9 ± 1.6 | 22.0 ± 1.5 | 39 |
| | | | | 34.0±2.0 | 39 |
| | 249.7 | $3s^2S \rightarrow 2p^2P^0$ | 4.5±0.7 | | 40 |
| Boron chloride | 272.4 ^b | $A^{-1}\Pi \rightarrow X^{-1}\Sigma^+$ | 1.9±0.4 | 14.0±1.5 | 39 |
| | | | | 29.0±2.0 | 39 |
| | 271.5° | $A^{1}\Pi \rightarrow X^{1}\Sigma^{+}$ | 1.9 ± 0.3 | | 40 |

^aEstimated uncertainty ±50%.

^bThe wavelength refers to the location of the maximum intensity of the $\Delta \nu = 0$ vibrational sequence of the $A^{1}\Pi \rightarrow X^{1}\Sigma^{+}$ band.

^cUnresolved (0,0), (1,1), and (2,2) bands.

photophysical studies have been made to probe the properties of BCl₃ gas discharges. Discharges containing BCl₃ provide a convenient source of BCl radicals whose Stark-mixed laser-induced fluorescence spectrum can be used to determine the magnitude of the sheath electric field with high spatial and temporal resolution.⁹¹ For instance, Gottscho⁹² used Stark-mixed laser-induced fluorescence to measure space-time-resolved maps of sheath electric fields in discharges through BCl₃ and in mixtures of BCl₃ with Ar as a function of power density $(0.14-0.41 \text{ W cm}^{-3})$ and frequency (dc to 10 MHz).

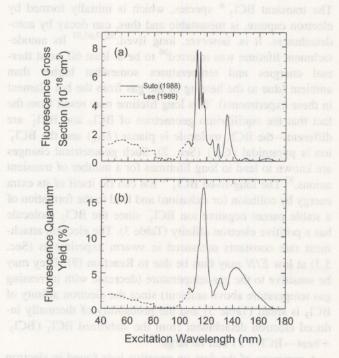


FIG. 12. (a) Fluorescence cross section and (b) fluorescence quantum yield as a function of excitation wavelength for BCl_3 : (---) Ref. 44; (---) Ref. 45.

5. Electron Attachment

Electron attachment to BCl_3 has been experimentally investigated using electron beam^{31–34,36,37} and electron swarm^{61,93} methods. There have also been some studies of negative ion formation in BCl_3 gas discharges.^{65,94,95} The results of these investigations are synthesized, assessed, and discussed in this section.

5.1. Electron Attachment Processes in BCl₃

Collectively, the results of a number of electron-beam mass spectrometric studies^{31-33,36,37} on the relative cross sections for the production of fragment negative ions by low-energy electron impact on BCl₃, are consistent with the reactions

 $BCl_3 + e \rightarrow BCl_3^{-*} \rightarrow BCl_2 + Cl^{-}, \tag{7}$

 $BCl_3 + e \rightarrow BCl_3^{-*} \rightarrow BCl + Cl_2^{-}, \qquad (8)$

and

 $BCl_3 + e \rightarrow BCl_3^{-*}$ (long lived). (9)

They all show that dissociative electron attachment to BCl₃ produces primarily Cl⁻ via Reaction (7). These studies^{32,33,36,37} also showed the production of Cl₂⁻ via Reaction (8) albeit with much smaller probability (the amount of Cl₂⁻ ions may be affected by ion-molecule reactions³³). The existence of long lived BCl₃^{-*} ions [Reaction (9)] at thermal electron energies has been indicated by electron beam^{36,37} and by electron swarm studies (see later in this section). These findings are discussed further below.

The dissociative electron attachment Reaction (7) is endoergic by $\sim 1 \text{ eV}$. Olthoff³⁶ estimated the energy threshold for Cl⁻ to be $\sim 0.7 \text{ eV}$ from thermodynamic data, and Baeck and Bartlett²⁹ calculated the dissociation energy of BCl₃⁻ into BCl₂ + Cl⁻ to be $\sim 1.59 \text{ eV}$. In accord with these values, Stockdale *et al.*³² found the lowest peak in the relative cross

Cl⁻ Relative Intensity (arb. units) Marriott (1957) 100 Stockdale (1972) - 0.083 Pa Stockdale (1972) - 0.009 Pa + Olthoff (1985) Brüning (1999) 80 60 40 20 0 0.1 1 10 Electron Energy (eV)

FIG. 13. Relative cross section for the production of Cl⁻ by electron impact on BCl3: (•) Ref. 31; (···) Ref. 32 for two pressures (0.009 and 0.083 Pa) showing the production of Cl⁻ directly via Reaction (7) at 1.1 eV and indirectly via Reactions (10a) and (10b) at higher energies (see text); (+) Ref. 36 under single-collision conditions; (- - -) Ref. 37 at a pressure of ~0.001 Pa.

section for the formation of Cl⁻ from BCl₃ to be located at (1.1 ± 0.1) eV, and Brüning³⁷ observed the most intense peak in the Cl⁻ production to be at ~0.9 eV (Fig. 13). However, in similar studies Olthoff³⁶ found the cross section for Cl⁻ to peak at an energy (Fig. 13) well below the thermodynamic threshold of 0.7 eV. Although the production of Cl is expected to be temperature dependent⁹⁶-and thus possible differences in the temperature of the various experimental studies may influence the magnitude and position of the lowenergy Cl⁻ resonance-the temperature in these experiments is not expected to differ appreciably. Brüning, for instance, quotes the temperature of his experiment to be ~340 K, and the temperature in the experiment of Olthoff is expected to be similar. Nonetheless, a study of the effect of temperature on the cross section for the production of Cl⁻ ions is indicated for this molecule. The observation of Cl- may also be attributed to impurities produced by reactions of the BCl3 with the gas manifold walls.

Besides the Cl⁻ peak near 1 eV, the relative cross section for the production of Cl⁻ from BCl₃ was found^{32,36,37} to have a number of weaker peaks between 6 and 10 eV (see Fig. 13 and Table 3) which are near the location of electron-excited Feshbach resonances observed in electron transmission studies.³⁰ Since the pressure in the experiments of Brüning³⁷ and Olthoff³⁶ was sufficiently low (on the order of 10⁻⁵ mbar) to ensure single-collision conditions, the Cl⁻ observed in these investigations between 6 and 10 eV is due to primary processes, that is, due to the decay of the negative ion states in this energy range via dissociative electron attachment. However, in the experiments of Stockdale et al.32 the pressure was much higher— $(9.2-82) \times 10^{-5}$ mbar-and in this case, in addition to the 1.1 eV peak, Stockdale et al. observed Cl⁻ peaks around 2.5 and 8 eV. The intensity of these peaks varied as the square of the BCl₃ pressure. They were attributed³² to the processes

$$BCl_3 \rightarrow BCl_3^* + e_{slow},$$

$$e_{\text{slow}} + \text{BCl}_3 \rightarrow \text{Cl}^- + \text{BCl}_2,$$
 (10b)

(10a)

which is due to the production of Cl - by dissociative attachment to BCl_3 of electrons, e_{slow} , that have first been slowed down to near 1 eV via the negative ion states near 2.5 eV and 8 eV.

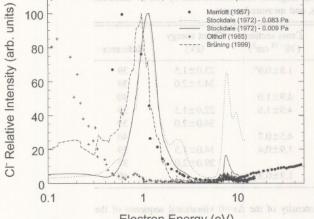
e+

In addition, the measurements of Marriott and Graggs³¹ shown in Fig. 13 indicate the production of Cl⁻ at energies ≥ 9 eV, which may be due to the ion-pair process BCl₃+e \rightarrow BCl₂⁺ + Cl⁻ + e. Marriott and Graggs were careful to point out however that because BCl₃ hydrolyzes readily (BCl₃ $+3H_2O \rightarrow H_3BO_3 + 3HCl)$, the production of HCl may affect the measurements dealing with the products Cl⁻, Cl⁺, and Cl⁺⁺ which may originate from electron impact on HCl.

The dissociative electron attachment Reaction (8) is also endoergic. Olthoff³⁶ estimated the threshold energy for Reaction (8) to be \sim 3.3 eV, and Baeck and Bartlett²⁹ calculated the dissociation energy of BCl_3^- into $BCl+Cl_2^-$ to be 4.01 eV. These values are incompatible with the observation by Stockdale et al.³² that the relative cross section of Cl₂ ions from BCl₃ peaks at 1.1±0.1 eV and the observations by Olthoff³⁶ and Brüning³⁷ that the relative cross section for the production of Cl₂ ions from BCl₃ peaks near 0.0 eV. Indeed, because of this discrepancy, the observed Cl₂ signals in these experiments may be due to impurities. Interestingly, Brüning observed BCl₄⁻, which Jiao et al.³³ found to be an ion-molecule reaction product resulting from the rapid reaction of Cl₂ with BCl₃. No BCl₂ or BCl⁻ fragment negative ions were reported in any of these studies.

Reaction (9) occurs at thermal and near-thermal energies. The transient BCl₃^{-*} species, which is initially formed by electron capture, is metastable and thus, can decay by autodetachment. It is, however, long lived. 36,37,65,93 Its autodetachment lifetime was inferred³⁶ to be at least 60 μ s at thermal energies and temperatures somewhat higher than ambient (due to the heating of the gas from the hot filament in these experiments). This long lifetime may result from the fact that the equilibrium geometries of BCl₃ and BCl₃ are different—the BCl₃ molecule is planar (D_{3h}) and the BCl₃ ion is pyramidal (C_{3v}) (Sec. 2). Such geometrical changes are known to lead to long lifetimes for a number of transient anions.⁹⁷ The long-lived BCl_3^{-*} ion can rid itself of its extra energy by collision (or radiation) and lead to the formation of a stable parent negative ion BCl₃ since the BCl₃ molecule has a positive electron affinity (Table 3). The electron attachment rate constants measured in swarm experiments (Sec. 5.3) at low E/N may thus be due to Reaction (9). They may be sensitive to the gas temperature (decrease with increasing gas temperature above ambient) since the electron affinity of BCl₃ is small (Table 3) and the probability of thermally induced electron detachment from the stabilized BCl₃ (BCl₃ + heat \rightarrow BCl₃+e) can be large.⁹⁸

A summary of the data on negative ions found in electron beam studies produced by low-energy electron impact on BCl₃ is given in Table 3 (see also Fig. 2).



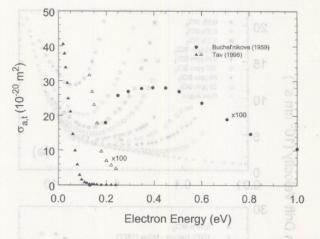


FIG. 14. Total electron attachment cross section as a function of electron energy, $\sigma_{a,t}(\epsilon)$, for BCl₃: (•) electron beam data from Ref. 34 (Note that these data have been multiplied by a factor of 100 for the convenience of display); (•) electron swarm data from Ref. 61 (the data shown with open triangles are multiplied by 100 to facilitate comparison).

5.2. Total Electron Attachment Cross Section as a Function of Electron Energy, $\sigma_{a,t}(\epsilon)$

There has been only one measurement of the total electron attachment cross section, $\sigma_{a,t}(\epsilon)$, of BCl₃ using the electron beam method, namely, that by Buche'nikova.³⁴ This total electron attachment cross section is shown in Fig. 14. It has a maximum at near 0.4 eV and a cross section value at this energy of 2.8×10^{-17} cm². While Buche'nikova's technique yields total electron attachment values, the data in Fig. 14 were attributed to the production of Cl⁻ via Reaction (7). As has been found for other molecules that Buchel'nikova had investigated, his cross section data for BCl₃ are considered to be lower than their true values.

5.3. Total Electron Attachment Rate Constant, $k_{a,t}$, as a Function E/N and $\langle \epsilon \rangle$

There have been two^{61,93} investigations of electron attachment to BCl₃ using the electron swarm method. Both of these studies employed mixtures of BCl₃ with N₂ and were conducted at room temperature (~ 295 K). In both studies the total electron attachment rate constant, $k_{at}(E/N)$, was measured as a function of the density-reduced electric field E/N. These measurements are compared in Fig. 15. The measurements of Petrović et al.93 have a quoted uncertainty of $\pm 30\%$. Although Tav *et al.*⁶¹ gave no uncertainty for their measurements, the uncertainty in their measurements is expected to be at least as large as that of Petrović et al.⁹³ considering the large variation of their data with time following the introduction of BCl₃ into their reaction chamber. Also shown in Fig. 15 is an earlier measurement³² (see Fig. 15 and Sec. 5.4) of the thermal electron attachment rate constant. There are substantial differences between these data, stressing the need for new measurements. Provide Training Petrović et al.⁹³ argued that since the threshold for dissociative electron attachment producing either Cl⁻ or Cl₂⁻ is

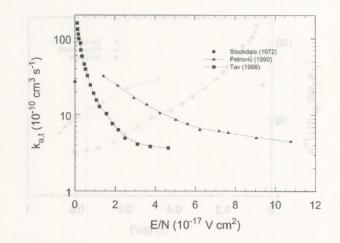


FIG. 15. Total electron attachment rate constant as a function of E/N, $k_{a,t}(E/N)$, for BCl₃: (**A**) Ref. 93; (**B**) Ref. 61; (**O**) thermal value from Ref. 32.

greater than $\sim 1 \text{ eV}$ and since for the E/N range they investigated the values of the mean electron energy are less than ~ 1 eV, the electron attachment rate constants they measured in their experiments (Fig. 15) are due to the formation of BCl₃. This interpretation would be consistent with the mass spectrometric observation^{36,37} of long lived BCl₃^{-*}, and with the conclusion of Gottscho and Gaebe⁶⁵ that BCl₃⁻ is the dominant negative ion formed in rf discharges using pure BCl3. Although Petrović et al. observed only Cl⁻ in dc discharges of BCl3, they argued that the difference between the results of the dc and rf discharge studies may be due to the difference in the electron energies in the types of discharges. In DC discharges the mean electron energies may be too high to enable production of BCl₃, in contrast to the bulk of rf plasma where the electron energies are much lower (see also Ref. 65).

Similarly, Tav et al.⁶¹ attributed the total electron attachment rate constant they measured at low electron energies $(\leq 0.1 \text{ eV})$ to the formation of BCl₃, and the weaker electron attachment at higher energies to Cl^- formation. How-ever, neither in the study of Petrović *et al.*⁹³ nor in the study of Tav et al. were the negative ions directly identified. It is emphasized that this indirect inference of the identity of the ions needs further scrutiny. The argument, for instance, that Cl⁻ cannot be formed at low energies for energetic reasons may not be correct, if there is a large effect of temperature on the dissociative electron attachment process generating Cl⁻. Also, since the electron affinity of the BCl3 molecule is small (Table 3), the electron may be detached thermally from the stabilized BCl₃ ion at temperatures at and above ambient. Therefore, to fully characterize the electron attachment processes for this molecule, an investigation is needed of the temperature dependence of the formation of both Cl- and BCl_3^- .

The $k_{a,t}(E/N)$ data in Fig. 15 are plotted in Fig. 16 as a function of the mean electron energy, $\langle \epsilon \rangle$, using the $\langle \epsilon \rangle$ (E/N) data for N₂(T= 300 K) given in Table A.II of Christophorou and Olthoff.⁹⁶

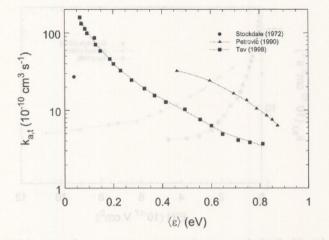


FIG. 16. Total electron attachment rate constant as a function of the mean electron energy $\langle \epsilon \rangle$, $k_{a,t}(\langle \epsilon \rangle)$, for BCl₃: (\blacktriangle) Ref. 93; (\blacksquare) Ref. 61; (\bullet) thermal value from Ref. 32.

5.4. Thermal Electron Attachment Rate Constant, $(k_{at})_{th}$

The thermal ($T \cong 295$ K) value, $(k_{a,i})_{th}$, of the total electron attachment rate constant of BCl₃ has been measured by Stockdale *et al.*³² to be 2.7×10^{-9} cm³ s⁻¹.

5.5. Swarm-Unfolded Total Electron Attachment Cross Section, $\sigma_{a,t}(\epsilon)$

Tav et al.⁶¹ unfolded the total electron attachment cross section $\sigma_{a,t}(\epsilon)$ shown in Fig. 14 from their data on $k_{a,t}(E/N)$ and the known electron energy distribution functions in the buffer gas N₂. They attributed the rise in the cross section below ~0.1 eV to the formation of BCl₃⁻. The smaller cross section at higher energies was attributed to Cl⁻ formation, but no direct identification of the negative ions was obtained. They indicated that their derived cross section has an uncertainty of ±20%, but the uncertainty is probably much larger than indicated. The disagreement between the swarmunfolded total electron attachment cross section⁶¹ and the beam-determined values³⁴ is large. Clearly, there is a need for further measurements.

5.6. Negative Ion Photodetachment in BCl₃ Plasmas

Gaebe *et al.*⁹⁴ described a spectroscopic diagnostic technique that provides the response of a radio-frequency discharge to electrons photodetached from negative ions in BCl₃. In this technique the spatially and temporally resolved charges in the local electric field of a 50 kHz discharge through BCl₃ (changes in the local electric field which resulted from photodetachment of electrons from negative ions) are monitored using Stark-mixing spectroscopy (e.g., see Refs. 91,99).

Similarly, Fleddermann and Hebner⁹⁵ investigated the Cl⁻ concentration and the electron density in BCl₃-containing inductively coupled plasmas using laser light to photodetach

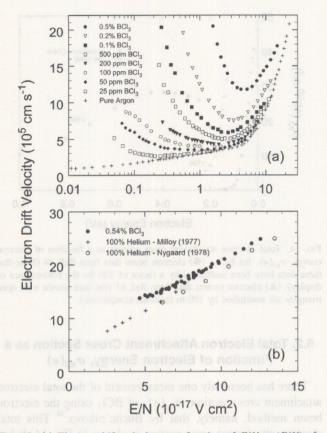


FIG. 17. (a) Electron drift velocity as a function of E/N, w(E/N), for mixtures of BCl₃ in argon (data of Mosteller *et al.* from Ref. 14). (b) Electron drift velocity as a function of E/N, w(E/N), for a 0.54% BCl₃ mixture with He [(\bullet) Ref. 14], in comparison with the w(E/N) for pure He [(+) Ref. 100; (\bigcirc) Ref. 101].

electrons from Cl⁻ ions. They detected the photodetached electrons and the steady-state electron density using a microwave interferometer, which allowed measurement of absolute negative ion densities as a function of gas mixture and reactor parameters. The 266 nm radiation from a frequencyquadrupled Nd:yttrium-aluminum-garnet laser was used for photodetachment. The plasma was probed at lower photon energy (355 nm) to photodetach electrons from other possible negative ions present in the plasma. To within the sensitivity of their measurement $(1.3 \times 10^8 \text{ cm}^{-3})$, no other negative ions (such as BCl_x⁻ or Cl₂⁻) were detected.

6. Electron Transport Coefficients

There are no measurements of the electron transport coefficients in pure BCl₃. However, there have been some measurements of the electron drift velocity, w(E/N), in BCl₃/Ar gas mixtures at concentrations of BCl₃ in Ar ranging from 2.5×10^{-5} to 5×10^{-3} , which are representative of those used in plasma applications.¹⁴ According to Mosteller *et al.*,¹⁴ these mixtures exhibit strong electron attachment at low E/N, and the w(E/N) measurements [shown in Fig. 17(a)] show regions of negative differential conductivity. Mosteller *et al.* also measured the w(E/N) in a mixture of 0.54% BCl₃ in He. These measurements are shown in Fig. 17(b), where they are compared with the w(E/N) of Milloy and Crompton¹⁰⁰ and Nygaard *et al.*¹⁰¹ for pure He.

7. Suggested and Needed Data

The only suggested electron collision data are those for $\sigma_{i,t}(\epsilon)$ (Fig. 9; Table 7). There is a need for further measurements of this cross section, and also for measurements of the cross sections of all other principal electron scattering processes for this molecule. Measurements are also needed of the electron transport, ionization, and attachment coefficients in pure BCl₃ and in mixtures.

8. Acknowledgments

We wish to thank Professor E. Illenberger for providing us with parts of Dr. F. Brüning's dissertation and Professor M. Hayashi for making available to us his literature list on BCl₃.

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